**CLAIM AMENDMENTS** 

This listing of claims will replace all prior versions, and listings, of claims in the

application:

1. (Previously Presented) A method, comprising:

directing an optical beam into a first end of an optical path having the first end

and a second end disposed in a semiconductor substrate;

reflecting a first portion of the optical beam having a first center wavelength back

out from the first end of the optical path with first and second pluralities of silicon and

polysilicon interfaces, respectively, disposed in the semiconductor substrate along the

optical path between the first end and the second end, the first and second pluralities of

silicon and polysilicon interfaces oriented substantially perpendicular to the

semiconductor substrate; and

tuning the optical path to reflect a second portion of the optical beam having a

second center wavelength back out from the first end of the optical path.

2. (Original) The method of claim 1 further comprising confining the optical

beam to remain within the optical path between the first and second ends with an optical

waveguide disposed in the semiconductor substrate between the first and second ends.

3. (Cancelled)

4. (Previously Presented) The method of claim 1 wherein tuning the optical path

comprises adjusting a temperature of the first and second pluralities of silicon and

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polysilicon interfaces with a heater disposed proximate to the optical path through the semiconductor substrate.

5. - 6. (Cancelled)

7. (Previously Presented) The method of claim 1 wherein the first and second pluralities of silicon and polysilicon interfaces in the semiconductor substrate along the optical path form a Bragg grating.

8. - 29. (Cancelled)

30. (Previously Presented) A method, comprising:

directing an optical beam into a first end of an optical path having the first end and a second end disposed in a semiconductor substrate;

reflecting a first portion of the optical beam having a first center wavelength back out from the first end of the optical path by perturbing an effective index of refraction a plurality of times along the optical path with a plurality of insulated conductor structures protruding into the optical path; and

tuning the optical path to reflect a second portion of the optical beam having a second center wavelength back out from the first end of the optical path.

31. (Previously Presented) The method of claim 30 wherein perturbing the effective index of refraction the plurality of times along the optical path comprises applying a voltage to the plurality of insulated conductor structures to perturb a concentration of free charge carriers a plurality of times along the optical path.

Attorney Docket No.: 42390P11429 Application No.: 09/881,218 32. (Previously Presented) The method of claim 30 wherein tuning the optical

path comprises modulating charge in the optical path by modulating a voltage applied to

the insulated conductor structures.

33. (Previously Presented) The method of claim 30, further comprising

confining the optical beam to remain within the optical path between the first and second

ends with an optical waveguide disposed in the semiconductor substrate between the

first and second ends.

34. (Previously Presented) The method of claim 32 wherein confining the optical

beam with the optical waveguide comprises forming the optical waveguide with

dielectric layers of a silicon-on-insulator wafer.

35. (Previously Presented) The method of claim 30 wherein perturbing an

effective index of refraction a plurality of times along the optical path with a plurality of

insulated conductor structures protruding into the optical path forms a Bragg grating.

36. (Previously Presented) The method of claim 2 wherein confining the optical

beam to remain within the optical waveguide comprises forming the optical waveguide

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with dielectric layers of a silicon-on-insulator wafer.

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37. (New) A method, comprising:

directing an optical beam into a first end of an optical path having the first end

and a second end disposed in a semiconductor substrate;

reflecting a first portion of the optical beam having a first center wavelength back

out from the first end of the optical path with at least three silicon and polysilicon

interfaces disposed in the semiconductor substrate along the optical path between the

first end and the second end, the at least three silicon and polysilicon interfaces forming

a Bragg grating; and

tuning the at least three silicon and polysilicon interfaces to reflect a second

portion of the optical beam having a second center wavelength back out from the first

end of the optical path.

38. (New) The method of claim 37 wherein the at least three silicon and

polysilicon interfaces are oriented substantially perpendicular to the semiconductor

substrate.

39. (New) The method of claim 38 wherein tuning the at least three silicon and

polysilicon interfaces comprises adjusting a temperature of the at least three silicon and

polysilicon interfaces with a heater disposed proximate to the optical path through the

semiconductor substrate.

40. (New) A method, comprising:

directing an optical beam into a first end of an optical path having the first end

and a second end disposed in a semiconductor substrate;

establishing a Bragg grating within the optical path with a plurality of electrodes

positioned to perturb an effective index of refraction a plurality of times along the

optical path;

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reflecting a first portion of the optical beam having a first center wavelength back out from the first end of the optical path with the Bragg grating; and

tuning the Bragg grating to reflect a second portion of the optical beam having a second center wavelength back out from the first end of the optical path.

- 41. (New) The method of claim 40 wherein establishing the Bragg grating within the optical path comprises applying a voltage to the plurality of electrodes to perturb a concentration of free charge carriers a plurality of times along the optical path.
- 42. (New) The method of claim 41, wherein tuning the Bragg grating comprises modulating charge in the optical path by modulating the voltage applied to the plurality of electrodes.
- 43. (New) The method of claim 41, further comprising confining the optical beam to remain within the optical path between the first and second ends with an optical waveguide disposed in the semiconductor substrate between the first and second ends.

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